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Citation

Liao, Kung-Ching, Hyo Jae Yoon, Carleen M. Bowers, Felice C. Simeone, and George M. Whitesides. 2014. "Replacing Ag TS SCH 2 -R with Ag TS 0 2 C-R in EGaIn-Based Tunneling Junctions Does Not Significantly Change Rates of Charge Transport." *Angewandte Chemie International Edition* 53, no. 15: 3889–3893.

Published Version

doi:10.1002/anie.201308472

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Replacing $\text{Ag}^{\text{TS}}\text{SCH}_2\text{-R}$ with $\text{Ag}^{\text{TS}}\text{O}_2\text{C-R}$ in EGaIn-Based Tunneling Junctions Does Not Significantly Change Rates of Charge Transport

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Abstract:

This paper compares rates of charge transport by tunneling across junctions with the structures $\text{Ag}^{\text{TS}}\text{X}(\text{CH}_2)_{2n}\text{CH}_3//\text{Ga}_2\text{O}_3/\text{EGaIn}$ ($n = 1 - 8$ and $\text{X} = -\text{SCH}_2-$ and $-\text{O}_2\text{C}-$); here Ag^{TS} was template-stripped silver, and EGaIn is the eutectic alloy of gallium and indium. Its objective was to compare the tunneling decay coefficient (β , $\text{\AA}^{-1}$) and the injection current (J_0 , A/cm^2) of the junctions comprising SAMs of *n*-alkanethiolates and *n*-alkanoates. Replacing $\text{Ag}^{\text{TS}}\text{SCH}_2-\text{R}$ with $\text{Ag}^{\text{TS}}\text{O}_2\text{C}-\text{R}$ ($\text{R} = \text{alkyl chains}$) had no significant influence on the value of J_0 (*ca.* $3 \times 10^3 \text{ A}/\text{cm}^2$) or on the value of β ($0.75 - 0.79 \text{ \AA}^{-1}$); an indication that such changes (both structural and electronic) in the $\text{Ag}^{\text{TS}}\text{XR}$ interface do not influence the rate of charge transport. A comparison of junctions comprising oligo(phenylene)carboxylates and *n*-alkanoates showed, as expected, that the value of β for aliphatic ($0.79 \text{ \AA}^{-1}$) and aromatic ($0.60 \text{ \AA}^{-1}$) SAMs differed significantly.

Studies of charge tunneling through self-assembled monolayer (SAM)-based junctions have focused predominately on the influence of backbone substituents¹⁻⁴ or terminal functional groups⁵⁻⁸ on rates of charge transport. The effect of changing the group (which we call the “anchoring group”) that links the SAM to the metal substrate has not been explored in detail;^{9, 10} only a few studies have approached this issue at the single-molecular level using scanning tunneling microscopy¹¹⁻¹⁴ or conducting atomic force microscopy.¹⁵⁻¹⁷ Here we explore the replacement of the anchoring group using a large-area (50 μm^2 on average) SAM-based junction having the structure $\text{Ag}^{\text{TS}}\text{-X-(CH}_2\text{)}_{2n}\text{CH}_3\text{//Ga}_2\text{O}_3\text{/EGaIn}$,^{18, 19} where X is the anchoring group for the SAM; Ag^{TS} is a template-stripped silver substrate;²⁰ EGaIn is a liquid metal, eutectic gallium–indium alloy; and Ga_2O_3 is a thin semiconducting film that forms spontaneously on the surface of EGaIn in air.¹⁸ We prepared analogous junctions, compositionally different only in the replacement of $\text{Ag}^{\text{TS}}\text{SCH}_2\text{-R}$ with $\text{Ag}^{\text{TS}}\text{O}_2\text{C-R}$, and compared the rates of charge transport by tunneling through these two junctions. The similarity in these rates establishes that the rate of charge transport across the SAM-based tunneling junction is surprisingly insensitive to changes in the composition of the interface between the Ag^{TS} and the SAM.

While the study of organothiolates in molecular electronics is limited by the availability and stability of thiols, a large variety of carboxylic acids are commercially available, or easily accessible by straightforward synthetic routes. The ability to study charge transport through junctions of the structure $\text{Ag}^{\text{TS}}\text{O}_2\text{CR//Ga}_2\text{O}_3\text{/EGaIn}$ makes mechanistic studies of tunneling more accessible experimentally, and provides a new system that helps to clarify the role of the interfaces to electrodes in tunneling junctions.

Background. The rate of charge transport by tunneling through SAMs decays exponentially with increasing distance between the top and bottom electrodes. In studies analogous to those in

many other systems, we determined that junctions of the structure $\text{Ag}^{\text{TS}}\text{SCH}_2\text{--}(\text{CH}_2)_{2n}\text{CH}_3//\text{Ga}_2\text{O}_3/\text{EGaIn}$ (across a range of molecular lengths and structures) obey the simplified Simmons equation (1),²¹⁻²⁴ where J (A/cm^2) is the measured current density; β ($\text{\AA}^{-1}$) is the tunneling decay coefficient; we take d ($\text{\AA}$) to be the extended length of molecule. The injection current, J_0 , represents the current density when $d = 0$; that is, the value of J for a

$$J = J_0 e^{-\beta d} \quad (1)$$

hypothetical system consisting only of the top and bottom electrodes, and the metal–SAM interfaces.²⁴ Values of β characterize tunneling junctions having a range of alkyl structures are similar; values of J_0 vary among different types of junctions, for reasons that are at least partially understood.¹⁹

In an electrode–SAM–electrode junction, charge crosses a tunneling barrier whose energetic topography is not exactly known, but which describes the space (including the SAM, the interfaces between the SAMs and the electrodes, and any surface films on the electrodes) between the two metallic junctions. In principle, one approach to manipulating the shape of the tunneling barrier, and thus to influencing the rate of charge transport, is to introduce functional groups into the structure of the SAM that are capable of influencing this topography, and thus the rate or mechanism of charge transport.²⁵⁻²⁹ Using $\text{Ga}_2\text{O}_3/\text{EGaIn}$ top-electrodes, however, we found previously that the tunneling current is insensitive to the incorporation of several functional groups familiar in organic chemistry^{4, 8} (e.g., an amide, --CONH-- or --NHCO--) in the backbone of the molecules in the SAM, or a variety of functional groups (both aliphatic and aromatic) that are not electrochemically active at the terminus of the SAM ostensibly in contact with the Ga_2O_3 film.⁸

Most studies using EGaIn-based tunneling junctions have focused on SAMs of *n*-alkanethiolates on Au or Ag. This focus on systems based on the Ag–SR anchoring group has limited our understanding of the role of the interface between the Ag (or Au) and the SAM to a single chemical and electronic structure. Here, we replaced *n*-alkanethiolates with *n*-alkanoates in order to examine the effect of the bottom-interface on the value of J_0 for a Ag^{TS}–SAM//Ga₂O₃/EGaIn junction. *n*-Alkanoic acids form highly-ordered monolayers on metal surfaces;³⁰ in particular, monolayers composed of long-chain *n*-alkanoates on Ag exhibit nearly crystalline packing of the hydrocarbon backbone, all-*trans* methylene conformations, and a bidentate ionic binding coordination of the carboxylate to the surface.^{30–33} Previous reports^{31, 33} showed that the carboxylate moiety coordinates through ionic interactions with the surface of the Ag, and a native oxide of Ag possibly (or in our view probably) exists at the interface between the metal and the carboxylate. SAMs of *n*-alkanethiolates on Ag(111) have a ($\sqrt{7} \times \sqrt{7}$)R10.9° cell with 4.4 Å nearest neighbor spacing.³⁴ The structure of *n*-alkanoate SAMs on Ag is comparable to that of *n*-alkanethiolates; the tilt angle of the alkyl chains is 15 – 25° (from the surface normal), and they form a *p*(2x2) overlayer with a lattice spacing of 5.8 Å, indicating a densely packed monolayer,^{34, 36} as summarized in Table S1 (see the supplementary information).

Results and discussion

Preparation of SAMs. We prepared SAMs with commercially available *n*-alkanoic acids, CH₃(CH₂)_{2n}CO₂H where *n* = 1 – 8 (i.e., the number of methylene groups). The preparation of *n*-alkanoate SAMs on Ag^{TS} followed previously reported literature procedures.^{30, 35} Freshly prepared Ag^{TS} substrates were introduced into a solution of 1 mM *n*-alkanoic acid in anhydrous *n*-hexadecane for 3 hr. After incubation at ambient conditions, we rinsed the SAM-bound Ag substrates three times with anhydrous hexane and dried the substrates under a gentle stream of

nitrogen. We characterized the surface of SAMs of *n*-alkanoates on Ag^{TS} using contact angle measurements. The monolayers exhibited low wettability: static contact angles for wetting by water and *n*-hexadecane were $113 \pm 7^\circ$ and $45 \pm 3^\circ$, respectively. These values are consistent with previous reports by Tao *et al.*³⁰ and Lin *et al.*³²

Measurements of Tunneling Currents. We measured $J(V)$ for junctions of the form Ag^{TS}O₂C–(CH₂)_{2n}CH₃//Ga₂O₃/EGaIn over the range of ± 0.5 V as a function of the length of alkyl chain ($n = 1 - 8$); we did not observe rectification of current (Figure 1b). Each curve of $\log|J(V)|$ versus V was generated with 430 – 720 data from at least 20 different junctions on three to four samples, and the yield of working junctions was $\geq 84\%$ (Table 1). As observed in many previous studies, the binned J values (100 bins in the range of $\log|J| = -6$ to 4, with units of A/cm²; the width of each bin is $\log|J| \sim 0.1$) had a distribution that was approximately log-normal; this form justified fitting each histogram of $\log|J|$ with a Gaussian curve. From these fittings, we obtained mean values of $\log|J|$ ($\log|J|_{\text{mean}}$) and standard deviations ($\sigma_{\log}$) of the corresponding Gaussian fits (Figure 2); $\log|J|_{\text{mean}}$ is indistinguishable from the log median value ($\log|J|_{\text{median}}$) of $\log|J|$ determined in each histogram (Table 1). Values of $\sigma_{\log}$ ranged from 0.1 to 0.5; these values are similar to those observed in the junctions of *n*-alkanethiolate SAMs.³⁶ As expected from the simplified Simmons equation, the rate of charge transport across junctions containing SAMs of *n*-alkanoates followed an exponential decrease with increasing length of the *n*-alkyl groups ($n=1$ to 8 for CH₃(CH₂)_{2n}CO₂). Figure 1c shows a plot of $\log|J|$ versus calculated length (Å) which includes the length of terminal H–C bond but excludes the length of Ag–O bond, which we considered to be a part of the Ag^{TS}–SAM interface (in this view [O₂]C(CH₂)_{2n}CH₃ and [S]CH₂(CH₂)_{2n}CH₃ are compatible structure). The linear-least square fit of the full set of data (CH₃(CH₂)_{2n}CO₂H, $n = 1 - 8$) yielded the log-injection current, $\log|J_0| = 3.5 \pm 0.2$ A/cm²

(coefficient of determination, $R^2 = 0.99$). The slope derived from the plot of $\ln|J|$ versus the length of molecules provided the tunneling decay coefficient, $\beta = 0.79 \pm 0.02 \text{ \AA}^{-1}$.

Comparisons of $J(V)$ data from n -alkanoate and n -alkanethiolate³⁶ SAMs on Ag (Table 1) indicate that these junctions have a statistically indistinguishable tunneling decay coefficient ($\beta = 0.79 \pm 0.02 \text{ \AA}^{-1}$ for n -alkanoates; $\beta = 0.75 \pm 0.02 \text{ \AA}^{-1}$ for n -alkanethiolates, both with even numbers of carbon atoms) and injection current ($\log|J_0| = 3.5 \pm 0.2 \text{ A/cm}^2$ derived from n -alkanoates; $\log|J_0| = 3.2 \pm 0.3 \text{ A/cm}^2$ derived from n -alkanethiolates). The similarities in β and J_0 imply that any difference in the contribution of the Ag-thiolate and the Ag-oxygen interface to the shape of the tunneling barrier is not detectable by our methods, although these two interfaces are chemically and electronically quite different. We conclude therefore, that the $\text{Ag}^{\text{TS}}\text{-X-R}$ interface does not contribute to the features of the tunneling barrier that influence tunneling current. While we and Tao *et al.* have not yet defined whether mono- or multi-layers of native silver oxide are sandwiched between the Ag metal and the carboxylate, the J - V measurements suggest that this film, if any, is conductive, and makes no contribution to the resistance of the junction.

Several studies have predicted or reported a distinct electronic influence from different metal-molecule interfaces used in junction measurements.^{11, 37-40} For example, Zimbovskaya and Pederson⁴¹ examined different metal-molecule interfaces theoretically, and concluded that different modes of binding at the interfaces might influence the conductance of junctions. Chu *et al.*⁴² reported that the current through molecules with an Au-amine junction is larger by a factor of 10 than that with an Au-thiolate linkage, and attributed this observation to the difference of the electronic interactions between the gold and the anchoring group. Our findings, however, indicate that replacing $\text{AgSCH}_2\text{-R}$ with $\text{AgO}_2\text{C-R}$ (a large change in the structure of the bottom

metal–SAM interface) has no significant influence on the rates of charge transport across *n*-alkyl-based SAMs.

Junctions comprising SAMs of aromatics. Tao and coworkers reported the formation and characterization of SAMs of biphenyl-4-carboxylic acid⁴³ and *p*-terphenyl-4-carboxylic acid³³ on Ag. Their report showed that the oligo(phenylene)carboxylate binds perpendicularly (from the surface normal) through a symmetric ionic coordination to the surface of Ag.⁴³ We incorporated SAMs of oligo(phenylene)carboxylic acids into junctions of the structure $\text{Ag}^{\text{TS}}\text{O}_2\text{C}(\text{C}_6\text{H}_4)_n\text{H}/\text{Ga}_2\text{O}_3/\text{EGaIn}$ ($n = 1 - 3$) and characterized rates of charge transport across them (Figure 3a; Table 2). Figure 4 shows the histograms of $\log|J|$ at -0.5 V and relative Gaussian fittings for benzoic acid, biphenyl-4-carboxylic acid, and *p*-terphenyl-4-carboxylic acid. We found a narrow distribution of current density with a small range of $\sigma_{\log}$ (0.2 – 0.3) for each SAM. The value of $\log|J_0|$ ($3.0 \pm 0.2 \text{ A/cm}^2$) of the $\text{Ag}^{\text{TS}}\text{O}_2\text{C}(\text{C}_6\text{H}_4)_n\text{H}/\text{Ga}_2\text{O}_3/\text{EGaIn}$ junctions was estimated from a linear least squares fit ($R^2 = 0.98$) of the plot of $\log|J|$ versus the calculated length of the molecules ($\text{\AA}$); β was $0.60 \pm 0.2 \text{ \AA}^{-1}$.

The tunneling decay coefficient of *n*-alkanoate-based SAMs ($0.79 \text{ \AA}^{-1}$) is higher than that of oligophenylene-containing SAM ($0.60 \text{ \AA}^{-1}$), and suggests (as have other studies^{10, 29, 44, 45}) that in these oligophenylene-based SAMs i) the shape of the tunneling barrier is influenced both by the width of the tunneling barrier and the electronic structure of the molecules forming the SAM; ii) charge transport by tunneling through poly-aromatic SAMs is more rapid than through non-conjugated SAMs (a conclusion in agreement with a number of other studies). The value of $\log|J_0|$, derived from the junctions comprising SAMs of oligophenylene carboxylates ($\log|J_0| = 3.0 \pm 0.2 \text{ A/cm}^2$), is indistinguishable to that of *n*-alkanoates ($\log|J_0| = 3.5 \pm 0.2 \text{ A/cm}^2$) at the precision of our measurements.

Conclusion

Within the constraints of the accuracy and uncertainties of our system, the Ag–SAM interface has no significant influence on the rates of tunneling across an *n*-alkane-based tunneling barrier, since the tunneling currents through junctions of *n*-alkanoate and of *n*-alkanethiolate SAMs are indistinguishable in our experiments. Although the details of the bonds at the Ag^{TS}O₂C–R interface are quite different from those at the Ag^{TS}SCH₂–R interface,^{31, 33} this study suggests that nature of the coordination between the metal of bottom electrode (Ag^{TS}) and the SAM does not significantly influence the rate of tunneling. The tunneling decay coefficient for *n*-alkanoates and for *n*-alkanethiolates on silver are indistinguishable (0.75–0.79 Å⁻¹), and are similar to previous literature reports for junctions with different structures.^{19, 46-48} The coefficient for oligophenylene carboxylates ($\beta = 0.60$ Å⁻¹) is, as expected from prior work, significantly lower than that of alkyl-based SAMs.

We conclude that the Ag^{TS}O₂CR//Ga₂O₃/EGaIn junction provides a versatile and convenient experimental system with which to investigate factors that may influence rates of charge transport through SAM-based junctions, and to understand the mechanisms underlying these influences. The use of carboxylate anchoring groups promises to simplify the study of tunneling junctions greatly by eliminating the instability (due to oxidation, desulfurization, and other processes) and multiple chemical incompatibilities of the commonly-studied structures based on organic thiolates. Moreover, carboxylates are more flexible than thiols from the vantage of physical-organic studies, because they are commercially available, stable (especially to oxidation), and easily handled and purified.

Methods

See the Supplementary Information for the materials, sample preparations, and procedures for measurements of tunneling.

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Acknowledgements

We thank Dr. Mathieu Gonidec for his technical contribution. This work was supported by a subcontract from Northwestern University from the Department of Energy (DE-SC0000989) on materials and measurements of charge transport.

Author contributions

K.-C.L. and G.M.W. conceived this project. K.-C.L. performed the experiments of carboxylates; F.C.S. performed the experiments of *n*-alkanethiolates. All authors analysed the junction measurements, discussed the results, and contributed to the manuscript.

Additional Information

Supplementary information including Table S1 is available in the online version of the paper.

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Competing financial interests

The authors declare no competing financial interests.

Figure 1. a, A cartoon representation of the $\text{Ag}^{\text{TS}}\text{XR//Ga}_2\text{O}_3/\text{EGaIn}$ junction ($\text{X} = -\text{SCH}_2-$ and $-\text{O}_2\text{C}-$); **b**, log-current density ($\log|J|$) versus bias (V) plots for the $\text{Ag}^{\text{TS}}\text{O}_2\text{C}(\text{CH}_2)_n\text{CH}_3/\text{Ga}_2\text{O}_3/\text{EGaIn}$ junctions with various chain lengths (4 to 18 carbons including the top methyl group and the bottom anchoring group), as indicated in the figure; **c**, a plot of log-current density ($\log|J|$) against the chain length of *n*-alkanoates (including the terminal C–H bond), given in number of carbons at -0.5 V. The linear-least square fits for *n*-alkanoates (dotted line) and for *n*-alkanethiolates (solid line) and the results of electrical measurement are inserted in the figure.

Figure 2. Histograms for values of $\log|J|$ data derived from *n*-alkanoates at -0.5 V. Each histogram is fitted with a Gaussian curve (black curve).

Figure 3. a, A cartoon representation of the junction structure comprising oligo(phenylene)-carboxylate SAMs. The carboxylate forms a bidentate coordination to the surface of Ag; **b**, a plot of log-current density ($\log|J|$) against the calculated length ($\text{\AA}$), including the terminal C–H bond, of oligo(phenylene)carboxylates, given in the number of phenylene units at -0.5 V. The linear-least square fits (dotted line) and the results of electrical measurement are inserted in the figure.

Figure 4. Histograms of $\log|J|$ for **a**, benzoate; **b**, biphenyl-4-carboxylate; and **c**, *p*-terphenyl-4-carboxylate in the $\text{Ag}^{\text{TS}}\text{O}_2\text{C}(\text{C}_6\text{H}_4)_n\text{H}/\text{Ga}_2\text{O}_3/\text{EGaIn}$ junctions ($n = 1 - 3$) at -0.5 V. Each histogram is fitted with a Gaussian curve (black curve).

Table 1. Summary of data derived from *n*-alkanoates (C_nO_2) and *n*-alkanethiolates³⁶ (C_nS) at -0.5 V to illustrate the similarity in the charge transport characteristics among the two homologous SAMs.

<i>n</i> -alkanoates							<i>n</i> -alkanethiolates	
C_nO_2	Number of Samples	Working Junctions	Yield (%)	traces	$\log J _{\text{median}}$ (A/cm^2)	$\log J _{\text{mean}} \pm \sigma_{\log}$ (A/cm^2)	C_nS	$\log J _{\text{mean}} \pm \sigma_{\log}$ (A/cm^2)
C_4O_2	3	20	95	432	1.85	1.9 ± 0.10	C_4S	1.6 ± 0.5
C_6O_2	3	20	90	467	0.95	1.0 ± 0.20	C_6S	0.9 ± 0.3
C_8O_2	4	30	97	721	-0.05	-0.06 ± 0.06	C_8S	0.2 ± 0.3
$C_{10}O_2$	4	29	91	668	-0.85	-0.8 ± 0.20	$C_{10}S$	-1.1 ± 0.3
$C_{12}O_2$	3	27	90	637	-1.65	-1.6 ± 0.20	$C_{12}S$	-1.5 ± 0.5
$C_{14}O_2$	4	32	97	719	-2.65	-2.7 ± 0.10	$C_{14}S$	-2.2 ± 0.3
$C_{16}O_2$	3	24	91	556	-3.55	-3.5 ± 0.20	$C_{16}S$	-3.2 ± 0.3
$C_{18}O_2$	4	32	84	717	-4.15	-4.1 ± 0.50	$C_{18}S$	-3.9 ± 0.3
C_0O_2						-3.5 ± 0.20 ($\log J_0 $) $\beta = 0.79 \pm 0.02 \text{ \AA}^{-1}$	C_0S	3.2 ± 0.3 ($\log J_0 $) $\beta = 0.75 \pm 0.02 \text{ \AA}^{-1}$

Table 2. Summary of data derived from oligo(phenylene)carboxylates ($\text{Ag}^{\text{TS}}-\text{O}_2\text{C}-(\text{C}_6\text{H}_4)_n\text{H}/\text{Ga}_2\text{O}_3/\text{EGaIn}$, $n = 1 - 3$) at -0.5 V.

Oligo(phenylene)carboxylates							
n	Molecular Lengths ($\text{\AA}$)	Number of Samples	Working Junctions	Yield (%)	traces	$\log J _{\text{median}}$ (A/cm^2)	$\log J _{\text{mean}} \pm \sigma_{\log}$ (A/cm^2)
1	6	3	18	72	343	1.45	1.5 ± 0.2
2	10	3	12	80	253	0.15	0.2 ± 0.2
3	14	3	15	79	300	-0.55	-0.6 ± 0.3
C_0O_2							3.0 ± 0.2
							$(\log J_0)$
							$\beta = 0.60 \pm 0.02 \text{ \AA}^{-1}$

Graphical Abstract

This manuscript describes a comparative study on the role of the metal–SAM interface in the charge tunneling process. We investigate the rate of charge transport through EGaIn-based junctions comprising self-assembled monolayers (SAMs) of organo-thiolates and carboxylates.